

2812 IFW

In Re Application of:	)
Bao et al.	) Group Art Unit: 2812
Serial No.: 10/618,527	) Examiner: Guerrero, Maria F.
Filed: July 11, 2003	) Confirmation No.: 5054
For: Semiconductor Device And Method For PreventingDamage To Anti-Reflective Structure During Removing An Overlying Photoresist Layer	) TKHR Docket: 252011-1510 ) Top-Team Ref. 0503-9677US )

## Certificate of Mailing

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postage prepaid, in an envelope addressed to: Mail Stop Amendment; Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450, on May 13, 2004.

Signature - Hui Chin Barnhill

## **AMENDMENT AND RESPONSE TO OFFICE ACTION**

Mail Stop Non-Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed March 2, 2004, has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.